Sunbin DENG (邓孙斌, 鄧孫斌), Ph.D.

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EDUCATION

09/2014 – 06/2020 Ph.D. in Electronic and Computer Engineering,

The Hong Kong University of Science and Technology (HKUST), Hong Kong

Supervisor: Prof. Hoi Sing KWOK & Prof. Man WONG

09/2010 – 06/2014 B.Sc. in Opto-Information Science and Technology (with Honors),

Huazhong University of Science and Technology (HUST), Wuhan, China

RESEARCH INTERESTS

Back-end-of-line (BEOL) compatible emerging semiconductor electronics (e.g., oxide electronics) and processing technologies for monolithic 3D integrated circuits (e.g., on-chip voltage converters), alternative computing hardware, and information display systems. All in a commitment to the development of integrated chips for artificial intelligence.

AWARDS & HONORS

- 1. Best Theme Poster Award, the 1st Annual Review of the Center for Heterogeneous Integration of Micro Electronic Systems (CHIMES, one of the SRC/DARPA JUMP 2.0 centers), 2023
- 2. Member, SID Display Future Star Committee, 2023
- 3. Distinguished Paper Award, Society for Information Display's Display Week, 2021
- 4. Young Leader Award, International Conference on Display Technology, 2021
- 5. Best Paper Award, Young Leaders in Displays (HK) and Postgraduate Workshop, 2021
- 6. Student Travel Grant, Society for Information Display's Display Week, 2019
- 7. Academic Award for PhD Students, School of Engineering, HKUST, 2019
- 8. Best Poster Presentation Award, Postgraduate Workshop on Display Research, 2018
- 9. Student Travel Grant, Society for Information Display's Display Week, 2018
- 10. Distinguished Poster Award, The International Display Manufacturing Conference, 2017
- 11. Best Oral Presentation Award, Postgraduate Workshop on Display Research, 2016
- 12. Distinguished Paper Award, The International Display Manufacturing Conference, 2015
- 13. Full postgraduate scholarship, HKUST, 2014-2020
- 14. Outstanding Graduate, HUST, 2014
- 15. Merit Student, HUST, 2013
- 16. Undergraduate Scientific and Technological Innovation Activist, *HUST*, 2012

RESEARCH EXPERIENCE

09/2022 - present School of Electrical and Computer Engineering, Georgia Institute of

Technology (GaTech), Atlanta

Supervisor: Prof. Suman DATTA Position: Postdoctoral Fellow

- 1. Amorphous oxide semiconductor (AOS) power transistors for on-chip voltage conversion
 - a) Invented BEOL compatible AOS power transistors for 12-volt operation.
 - b) Developed monolithic co-integration technology of depletion- and enhancement-mode AOS power

transistors.

- c) Fabricated high-breakdown-voltage superlattice capacitors based on laminate fluorites.
- d) Demonstrated switched-capacitor DC-DC converter circuits for efficient on-chip voltage conversion for multi-tier 3D integrated transformer accelerators.

2. AOS access and ferroelectric transistors for Computing in-Memory (CiM) Hardware

- a) Improved reliability of scaled AOS access transistors (L_g < 100 nm) with a dual-gate structure.
- b) Explored performance-reliability boosters (device structure, fabrication processes, etc.) in ALD AOS access transistors.
- c) Developed asymmetric dual-gated AOS ferroelectric field-effect transistors (FeFETs) with area efficiency improved and read/write disturbance suppressed in CiM bit cells.

09/2021 – 08/2022 School of Materials Engineering, Purdue University, West Lafayette

Supervisor: Prof. Shriram RAMANATHAN

Position: Postdoctoral Researcher

1. Mott neuromorphic electronics enabled by selective-area doping technology

- a) Developed two-terminal proton-doped VO₂ artificial synapses.
- b) Demonstrated VO₂-based Mott homotypic neuromorphic platform by selective-area doping.

2. Hydrogenated Mott probabilistic bit (p-bit) generators

- a) Developed sub-nm scale mapping technique of hydrogen dopant distribution in VO₂.
- b) Demonstrated H_xVO₂ p-bit generators for energy-efficient error-tolerant probabilistic computing.

07/2020 – 08/2021 State Key Laboratory of Advanced Displays and Optoelectronics

Technologies (SKL of ADT), HKUST

Supervisor: Prof. Hoi Sing KWOK & Prof. Ching Wan TANG

Position: Postdoctoral Research Associate (in HK Research Talent Hub)

1. Extended research on AOS thin-film transistors (TFTs)

- a) Developed fluorination in-packaging (FiP) technology for cost-effective high-reliability AOS TFTs at a low thermal budget.
- b) Implemented low-voltage (i.e., ≤1 V) circuits with all-oxide TFTs for wearable/biological electronics.

2. Ultra-high-resolution SiN_x shadow mask technology for OLED displays

- a) Fabricated micron-thin self-tensioned (5000 ppi) SiN_x shadow masks.
- b) Demonstrated 3000-ppi 3-inch full-color OLED displays using the SiN_x shadow masks.

09/2014 – 06/2020 SKL of ADT, HKUST

Supervisor: Prof. Hoi Sing KWOK & Prof. Man WONG

Position: Ph.D. Candidate

1. Hybrid-phase indium-tin-zinc oxide (hp-InSnZnO) TFT technology

- a) Designed hp-InSnZnO channels by optimizing both element composition and crystal morphology.
- b) Investigated the relationship between channel properties and deposition conditions.
- c) Developed hybrid PECVD-SiO₂ stacks as gate insulators with an enhanced dielectric quality.
- d) Discovered gas permeability of gate electrodes as an effective aspect to modulate threshold voltage.
- e) Fabricated high-performance hp-InSnZnO TFTs with diverse (self-aligned, vertical, etc.) structures.
- f) Extracted compact models of the hp-InSnZnO TFTs.
- g) Prototyped a 2.2-inch AMOLED panel using the hp-lnSnZnO TFT technology.
- h) Implemented digital and analog integrated circuits applicable to sensor interfaces.

2. Bridged-grain (BG) poly-Si TFTs using laser interference lithography (LIL)

- a) Improved electrical characteristics of poly-Si channels with BG structure.
- b) Introduced a self-built LIL system to define submicron BG strips.
- 3. Large-area few-layered MoS₂ film deposition via magnetron sputtering

- a) Sputtered high-quality few-layer MoS₂ films on 4-inch Si wafers.
- b) Characterized the few-layer MoS₂ films using spectroscopic and microscopy technologies.
- c) Fabricated the few-layer MoS₂ transistors.

4. Development of new-generation micro-LED displays

- a) Investigated selective mass transfer and miniaturization techniques for micro-LED pixels.
- b) Intended to assemble micro-LED pixels on active-matrix backplanes with AOS TFTs.

5. Performance analysis of photoluminescence/electroluminescence (PL/EL) QD-LED displays

- a) Evaluated color gamut and system efficiency in PL QD-LED displays.
- b) Modeled light out-coupling efficiency of bottom-emitting EL QD-LEDs.

05/2011 – 06/2014 Wuhan National Laboratory for Optoelectronics (WNLO), HUST

Mentor: Prof. Jun ZHOU & Prof. Zhonglin WANG

Position: Undergraduate Research Assistant

- 1. Fabrication of self-cleaning flexible infrared nano-sensors enabled by carbon nanoparticles.
- 2. Development of three-dimensional ZnO porous films for self-cleaning ultraviolet photodetectors.
- 3. Demonstration of broadband photodetectors based on ZnO nanowire array and PbS quantum dots.

PROFESSIONAL ACTIVITIES

Participated Funding Programs

- 1. Projects supported by SRC/DARPA JUMP 2.0 program, DoE EFRC program, ARO Neuro Fund, Samsung Electronics, EMD Electronics, etc.
- 2. 03/2022 02/2024, "Research on Thin Film Encapsulation Technology for Flexible OLED Devices", GHP/006/20GD, HKD 1,096,250.00, funded by The Innovation and Technology Commission (ITC).
- 3. 11/2020 10/2022, "Flexible Metal-oxide Backplane Technology for RGB-Color Conversion OLED Displays", GHP/013/19SZ, HKD995,999.47, funded by The Hong Kong Government.
- 4. 11/2019 4/2022, "Flexible photodetector array with integrated electronics based on metal-oxide", SZSTI20EG15, HKD 1,924,371.93, funded by Shenzhen Sci & Tech Innovation Committee (SZSTI).
- 5. 09/2019 08/2021, "EMMO-Structure Metal-Oxide Thin-Film Transistor for the Next-Generation AMOLED Display", GHP/007/18GD, HKD 1,276,700.00, funded by The Innovation and Technology Commission (ITC).
- 04/2019 03/2020, "Study on InSnZnO Thin Film Transistors and its Active-Matrix Array for High Resolution AMOLED Displays", GZSTI17EG02, HKD 283,254.02, funded by Guangzhou Municipal Sci. & Tech. Bureau.
- 06/2017 05/2019, "Applications of Novel Metal-Oxide Thin-Film Transistor to Flat Panel Displays and Internet of Things (IoT)", IGN16EG17, HKD 200,000, funded by the Hong Kong University of Science and Technology.
- 8. 07/2013 01/2049, "State Key Laboratory on Advanced Displays and Optoelectronics Technologies (HKUST)", ITC-PSKL12EG02, HKD 98,750,000.00, funded by The Innovation and Technology Commission (ITC).
- 01/2012 12/2016, "Challenges in Organic Photo-Voltaic and Light-Emitting Diodes A Concerted Multi-Disciplinary and Multi-Institutional Effort", T23-713/11-1, HKD 5,000,000, funded by The Hong Kong Government.

Invited Talks

- 1. Title TBD, on 2024 IEEE Symposium on VLSI Technology & Circuits, Honolulu, USA, 06/2024.
- 2. "Fluorinated Metal Oxide Thin-Film Transistors with Low Process Thermal Budgets" on 2023 International Conference on Display Technology, Nanjing, China, 03/2023.
- 3. "Hybrid-Phase Metal Oxide Thin-Film Transistor Technology" on *Young Leader Conference of ICDT 2021*, Beijing, China, 06/2021.

4. "Hybrid-Phase Metal Oxide Thin-Film Transistors and their Applications" on *Shanghai University League's Forum for International Young Scholars*, Shanghai, China, 05/2020.

Organized Conferences/Workshops

- 1. Program committee member, *Cross-Strait Postgraduate Workshop on Display Research*, Guangzhou, China, 2016
- 2. Student helper, 16th International Conference on Ferroelectric Liquid Crystals, Hong Kong, 2016
- 3. Student helper, 6th International Photonics and OptoElectronics Meeting, Wuhan, China, 2013

Professional Affiliations

- 1. Member, Institute of Electrical and Electronics Engineers (IEEE)
- 2. Member, Society for Information Display (SID)

Reviewer

IEEE Electron Device Letters, IEEE Transactions on Electron Devices, Applied Physics Letters, Journal of the Society for Information Display, Scientific Reports, Thin Solid Films, Physical Review Applied, etc.

Editorial Board

Rare Metals

Teaching Assistant

- 1. Fundamentals of Photovoltaic and Renewable Energy (ELEC 4530), HKUST, 02/2018-06/2018
- 2. Digital Circuits and Systems (ELEC 2200), HKUST, 09/2015-06/2016
- 3. Synthesis and Characterization of Optoelectronic Materials, HUST, 09/2013-01/2014

PUBLICATIONS (Google Scholar)

Representative Publications

- 1. **S. Deng,** et al. "Selective area doping for Mott neuromorphic electronics", *Science Advances*, 9.11 (2023): eade4838.
- 2. **S. Deng**, et al. "BEOL Compatible Oxide Power Transistors for On-Chip Voltage Conversion in Heterogenous 3D (H3D) Integrated Circuits", 2023 IEEE International Electron Devices Meeting (IEDM), San Francisco, USA, Dec. 2023.
- 3. **S. Deng,** et al. "Demonstration of On-Chip Switched-Capacitor DC-DC Converters using BEOL Compatible Oxide Power Transistors and Superlattice MIM Capacitors", 2024 IEEE Symposium on VLSI Technology & Circuits, Honolulu, USA, June 2024.
- 4. **S. Deng**, *et al.* "Thermal Budget Reduction in Metal Oxide Thin-Film Transistors via Planarization Process", *IEEE Electron Device Letters*, 42.2 (2021): 180-183.
- 5. **S. Deng**, *et al.* "Gate Insulator Engineering in Top-Gated Indium-Tin-Oxide-Stabilized ZnO Thin-Film Transistors", *IEEE Electron Device Letters*, 40.7 (2019): 1104-1107.

Book Chapters

- 1. M. Zhang, **S. Deng,** Y. Yan, M. Wong, and H. S. Kwok, "Fundamentals of Metal-Oxide Thin-Film Transistors", in Semiconducting metal oxide thin-film transistors, IOP Publishing, Bristol, UK. DOI: 10.1088/978-0-7503-2556-1ch2.
- Journal Articles (52 articles in total including 21 articles as first/corresponding author)
- 1. **S. Deng**, *et al.* "Hydrogenated VO₂ Bits for Probabilistic Computing", *IEEE Electron Device Letters*, 44.10 (2023): 1776-1779.
- 2. **S. Deng,** et al. "Selective area doping for Mott neuromorphic electronics", *Science Advances*, 9.11 (2023): eade4838.
- 3. T. J. Park*, S. Deng*, et al. "Complex oxides for brain-inspired computing: A review", Advanced

- Materials (2022): 2203352. (*Equal contribution)
- 4. **S. Deng**, *et al.* "A Cost-Effective Fluorination Method for Enhancing the Performance of Metal Oxide Thin-Film Transistors", *Journal of the Society for Information Display*, 29.5 (2021): 318-327. **(Additional cover)**
- 5. **S. Deng**, *et al.* "Thermal Budget Reduction in Metal Oxide Thin-Film Transistors via Planarization Process", *IEEE Electron Device Letters*, 42.2 (2021): 180-183.
- 6. X. Yin*, **S. Deng***, *et al.* "Low Leakage Current Vertical Thin-Film Transistors with ITO-stabilized ZnO Channel", *IEEE Electron Device Letters*, 41.2 (2019): 248-251. **(*Equal contribution)**
- 7. **S. Deng,** *et al.* "Gate Insulator Engineering in Top-Gated Indium-Tin-Oxide-Stabilized ZnO Thin-Film Transistors", *IEEE Electron Device Letters*, 40.7 (2019): 1104-1107.
- 8. Y. Xu*, **S. Deng***, *et al.* "The Implementation of Fundamental Digital Circuits With ITO-Stabilized ZnO TFTs for Transparent Electronics", *IEEE Transactions on Electron Devices*, 65.12 (2018): 5395-5399. (*Equal contribution)
- 9. W. Zhong*, **S. Deng***, *et al.* "Feasible route for a large area few-layer MoS₂ with magnetron sputtering", *Nanomaterials*, 8.8 (2018): 590. **(*Equal contribution)**
- 10. **S. Deng,** *et al.* "Threshold voltage adjustment in hybrid-microstructural ITO-stabilized ZnO TFTs via gate electrode engineering", *IEEE Electron Device Letters*, 39.7 (2018): 975-978.
- 11. **S. Deng,** *et al.* "Hybrid-Phase Microstructural ITO-Stabilized ZnO TFTs with Self-Aligned Coplanar Architecture", *IEEE Electron Device Letters*, 38.12 (2017): 1676-1679.
- 12. **S. Deng,** *et al.* "Investigation of high-performance ITO-stabilized ZnO TFTs with hybrid-phase microstructural channels", *IEEE Transactions on Electron Devices*, 64.8 (2017): 3174-3182.
- 13. **S. Deng,** *et al.* "High-performance staggered top-gate thin-film transistors with hybrid-phase microstructural ITO-stabilized ZnO channels", *Applied Physics Letters*, 109.18 (2016): 182105.
- 14. **S. Deng,** *et al.* "Fabrication of high-performance bridged-grain polycrystalline silicon TFTs by laser interference lithography", *IEEE Transactions on Electron Devices*, 63.3 (2016): 1085-1090.
- 15. H. Li, **S. Deng^**, *et al.* "A Differential Ring Oscillator with Tail Current Source Control Scheme Using N-Type Oxide TFTs", *IEEE Transactions on Electron Devices*, 69.4 (2022): 1870-1875. **(^Corresponding author)**
- 16. Y. Xu, Z. Wu, B. Li, **S. Deng^**, *et al.* "Oxide TFT Frontend Amplifiers for Flexible Sensing Systems", *IEEE Transactions on Electron Devices*, 68.12 (2021): 6190-6196. (**^Corresponding author**)
- 17. Y. Xu, B. Li, W. Zhong, **S. Deng^**, *et al.* "A Unipolar TFT-Based Amplifier with Enhanced DC Offset Suppression", *Electronics Letters*, 57.2 (2021): 67-70. **(^Corresponding author)**
- 18. Y. Xu, W. Zhong, B. Li, **S. Deng^**, *et al.* "An Integrator and Schmitt Trigger Based Voltage-to-Frequency Converter Using Unipolar Metal-Oxide Thin Film Transistors", *IEEE Journal of the Electron Devices Society*, 9 (2020): 144-150. (**^Corresponding author**)
- 19. H. Fan, **S. Deng^**, *et al.* "A High Gain Low-Noise Amplifier based on ITO-Stabilized ZnO Thin-Film Transistors", *IEEE Transactions on Electron Devices*, 67.12 (2020): 5537-5543. (**^Corresponding author**)
- 20. Y. Xu, B. Li, **S. Deng^**, *et al.* "A Novel Envelope Detector Based on Unipolar Metal-Oxide TFTs", *IEEE Transactions on Circuits and Systems II: Express Briefs*, 67.11 (2020): 2367-2371. (^Corresponding author)
- 21. Y. Qin, G. Li, Y. Xu, R. Chen^, **S. Deng^**, *et al.* "Low-Power Design for Unipolar ITO-Stabilized ZnO TFT RFID Code Generator Using Differential Logic Decoder", *IEEE Transactions on Electron Devices*, 66.11 (2019): 4768-4773. (**^Corresponding author**)
- 22. A. Pofelski, H. Jia, **S. Deng**, *et al.* "Sub-nanometer Scale Mapping of Hydrogen Doping in Vanadium Dioxide", *Nano Letters*, 24.6 (2024): 1974-1980.

- 23. Y. Chen, Y. Liu, **S. Deng**, *et al.* "Low-frequency noise in InSnZnO thin film transistors with high-quality SiO2 gate oxide stacks", *Applied Physics Letters*, 124.2 (2024): 023501.
- 24. M. Zhang, Z. Jiang, **S. Deng**, *et al.* "Hot Carrier Degradation Accompanied by Recovery in InSnZnO Thin-Film Transistors", *IEEE Electron Device Letters*, 44.7 (2023): 1124-1127.
- 25. G Zhu, M Zhang, Z Jiang, J Huang, Y Huang, S Deng, et al. "Significant Degradation Reduction in Metal Oxide Thin-Film Transistors via the Interaction of Ionized Oxygen Vacancy Redistribution, Self-Heating Effect, and Hot Carrier Effect", IEEE Transactions on Electron Devices, 70.8 (2023): 4198-4205.
- J. Zhang, C. Yao, X. Liu, Z. Ding, Y. Liu, B. Liu, S. Deng, et al. "Controllable Transformation of 2D Perovskite for Multifunctional Sensing Properties", The Journal of Physical Chemistry C, 127.16 (2023): 7730-7739.
- 27. Z. Chen, M. Zhang, **S. Deng**, *et al.* "Effect of Moisture Exchange Caused by Low-Temperature Annealing on Device Characteristics and Instability in InSnZnO Thin-Film Transistors". *Advanced Materials Interfaces*, 9.14 (2022): 2102584. (Inside back cover)
- 28. Z. Luo, B. Liu, X. Luo, T. Zheng, **S. Deng**, *et al.* "A Generic Protocol for Highly Reproducible Manufacturing of Efficient Perovskite Light-Emitting Diodes Using In-Situ Photoluminescence Monitoring", *Advanced Materials Technologies*, 7.5 (2022): 2100987.
- 29. Z. Jiang, M. Zhang, **S. Deng**, *et al.* "Evaluation of Positive-Bias-Stress-Induced Degradation in InSnZnO Thin-Film Transistors by Low Frequency Noise Measurement", *IEEE Electron Device Letters*, 43.6 (2022): 886-889.
- 30. H. Yan, J. Huang, X. Zhang, M. Wang, J. Liu, C. Meng, **S. Deng**, *et al.* "A buried functional layer for inorganic CsPb0.75Sn0.25l2Br perovskite solar cells". *Solar RRL*, 6.4 (2022): 2100899.
- 31. W. Zhong, J. Zhang, Y. Liu, L. Tan, L. Lan, **S. Deng**, *et al.* "Gate Dielectric Treated by Self-Assembled Monolayers (SAMs) to Enhance the Performance of InSnZnO Thin-Film Transistors", *IEEE Transactions on Electron Devices*, 69.5 (2022): 2398-2403.
- 32. J. Zhang, W. Zhong, Y. Liu, J. Huang, **S. Deng**, *et al.* "A High-Performance Photodetector Based on 1D Perovskite Radial Heterostructure", *Advanced Optical Materials*, 9.24 (2021): 2101504.
- 33. X. Luo, T. Zheng, Z. Luo, J. Liu, **S. Deng**, *et al.* "Visual Electrocardiogram Synchronization Monitor Using Perovskite-Based Multicolor Light-Emitting Diodes", *ACS Photonics*, 8.11 (2021):3337-3345.
- 34. W. Zhong, L. Kang, **S. Deng**, *et al.* "Effect of Sc₂O₃ Passivation Layer on the Electrical Characteristics and Stability of InSnZnO Thin-Film Transistors", *IEEE Transactions on Electron Devices*. 68.10 (2021): 4956-4961.
- 35. W. Shi, L. Hu, Y. Liu, **S. Deng**, *et al.* "Arithmetic and Logic Circuits Based on ITO-Stabilized ZnO TFT for Transparent Electronics", *IEEE Transactions on Circuits and Systems I: Regular Papers*, 69.1 (2021): 356-365.
- 36. X. Yin, Y. Chen, G. Li, W. Zhong, **S. Deng**, *et al.* "Analysis of low frequency noise in in situ fluorine-doped ZnSnO thin-film transistors", *AIP Advances*, 11.4 (2021): 045326.
- 37. J. Huang, H. Yan, D. Zhou, J. Zhang, **S. Deng**, *et al.* "Introducing Ion Migration and Light-induced Secondary Ion Redistribution for Phase-stable and High-Efficiency Inorganic Perovskite Solar Cells", *ACS Applied Materials & Interfaces*, 12.36 (2020): 40364-40371.
- 38. M. Zhang, **S. Deng**, *et al.* "Reversely-Synchronized-Stress-Induced Degradation in Polycrystalline Silicon Thin-Film Transistors and Its Suppression by a Bridged-Grain Structure", *IEEE Electron Device Letters*, 41.8 (2020): 1213-1216.
- 39. Y. Liu, Y. Huang, **S. Deng**, *et al.* "Dimension Scaling Effects on Conduction and Low Frequency Noise Characteristics of ITO-Stabilized ZnO Thin Film Transistors", *IEEE Journal of the Electron Devices Society*, 8 (2020): 435-441.
- 40. M. Zhang, Y. Yan, G. Li, S. Deng, et al. "High-Performance Polycrystalline Silicon Thin-Film Transistors

- without Source/Drain Doping by Utilizing Anisotropic Conductivity of Bridged-Grain Lines", *Advanced Electronic Materials*, 6.2 (2020): 1900961.
- 41. J. Zhang, B. Ren, **S. Deng**, *et al.* "Voltage-dependent Multicolor Perovskite Electroluminescent Device", *Advanced Functional Materials*, 30.4 (2020): 1907074.
- 42. M. Zhang, X. Ma, **S. Deng**, *et al.* "Degradation Induced by Forward Synchronized Stress in Poly-Si TFTs and Its Reduction by a Bridged-Grain Structure", *IEEE Electron Device Letters*, 40.9 (2019): 1467-1470.
- 43. S. Weng, R. Chen, W. Zhong, **S. Deng**, *et al.* "High Performance Amorphous Zinc Tin Oxide Thin Film Transistors with Low Tin Concentration", *IEEE Journal of the Electron Devices Society*, 7 (2019): 632-637.
- 44. B. Ren, G. Yuen, **S. Deng**, *et al.* "Multifunctional Optoelectronic Device Based on an Asymmetric Active Layer Structure", *Advanced Functional Materials*, 29.17 (2019): 1807894. (Inside back cover)
- 45. M. Zhang, Y. Yan, G. Li, **S. Deng**, *et al.* "OFF-State-Stress-Induced Instability in Switching Polycrystalline Silicon Thin-Film Transistors and Its Improvement by a Bridged-Grain Structure", *IEEE Electron Device Letters*, 39.11 (2018): 1684-1687.
- 46. G. Li, **S. Deng**, *et al.* "Achieving High Open-Circuit Voltage for p-i-n Perovskite Solar Cells Via Anode Contact Engineering", *Solar RRL*, 2.10 (2018): 1800151.
- 47. R. Chen, **S. Deng**, *et al.* "Investigation of top gate GaN thin-film transistor fabricated by DC magnetron sputtering", *Journal of Vacuum Science & Technology B, Nanotechnology and Microelectronics: Materials, Processing, Measurement, and Phenomena*, 36.3 (2018): 032203.
- 48. R. Chen, W. Zhou, **S. Deng**, *et al.* "Passivation of Poly-Si Thin Film Employing Si Self-Implantation and Its Application to TFTs", *IEEE Journal of the Electron Devices Society*, 6 (2018): 240-244.
- 49. Y. Liu, **S. Deng**, *et al.* "Low-frequency noise in hybrid-phase-microstructure ITO-stabilized ZnO thin-film transistors", *IEEE Electron Device Letters*, 39.2 (2017): 200-203.
- 50. G. Li, Y. Jiang, **S. Deng**, *et al.* "Overcoming the Limitations of Sputtered Nickel Oxide for High-Efficiency and Large-Area Perovskite Solar Cells", *Advanced Science*, 4.12 (2017): 1700463.
- 51. Z. Xia, L. Lu, J. Li, Z. Feng, **S. Deng**, *et al.* "Characteristics of elevated-metal metal-oxide thin-film transistors based on indium-tin-zinc oxide", *IEEE Electron Device Letters*, 38.7 (2017): 894-897.
- 52. Y. Cao, **S. Deng**, *et al.* "Three-dimensional ZnO porous films for self-cleaning ultraviolet photodetectors", *RSC Advances*, 5.104 (2015): 85969-85973.
- Conference presentations (37 in total, including 19 oral and 18 poster presentations)
- 2024 IEEE Symposium on VLSI Technology & Circuits, Honolulu, USA, June 2024.
 "Demonstration of On-Chip Switched-Capacitor DC-DC Converters using BEOL Compatible Oxide Power Transistors and Superlattice MIM Capacitors" (Oral)
 and "On the Reliability of High-Performance Dual Gate (DG) W-doped In₂O₃ FET" (Oral)
- 2024 Device Research Conference (DRC), The University of Maryland, College Park, USA, June 2024.
 "Optimization of Backside of Silicon-Compatible High Voltage Superlattice Capacitor for 12V-to-6V On-Chip Voltage Conversion" (Oral)
- 3. 2023 IEEE International Electron Devices Meeting (IEDM), San Francisco, USA, Dec. 2023.

 "BEOL Compatible Oxide Power Transistors for On-Chip Voltage Conversion in Heterogenous 3D (H3D) Integrated Circuits" (Oral)

 and "Improved Reliability and Enhanced Performance in BEOL Compatible W-doped In₂O₃ Dual-Gate Transistor" (Oral)
- Microscopy and Microanalysis 2023, Minneapolis, USA, July 2023.
 "Dopant Mapping of Partially Hydrogenated Vanadium Dioxide using the Energy Loss Near Edge Structure Technique" (Oral)

- 5. 2023 IEEE International Symposium on the Physical and Failure Analysis of Integrated Circuits (IPFA), Pulau Pinang, Malaysia, July 2023.
 - "Long-Term Recovery Behavior in InSnZnO Thin-Film Transistors after Negative Bias Stress" (Poster)
- Society for Information Display's Display Week 2023, Log Angeles, USA, May 2023.
 "Ultrahigh-Resolution Corrugated Silicon Nitride Masks for Direct Patterning of OLED Microdisplays" (Oral)
- 2023 International Conference on Display Technology, Nanjing, China, March 2023.
 "Fluorinated Metal Oxide Thin-Film Transistors with Low Process Thermal Budget" (Oral) (Invited)
- 2022 MRS Fall Meeting & Exhibit, Boston, MA, USA, Nov. 2022.
 "VO₂ Insulator-Metal Phase Change Based Neuromorphic Materials and Devices" (Oral)
- 9. 2022 International Conference on Display Technology, Fuzhou, China, Oct. 2022. "3000-ppi Silicon Nitride Masks for Direct Patterning of OLED Microdisplays" (Oral)
- 10. 2022 International Conference on Display Technology, Fuzhou, China, Oct. 2022. "Frontend Amplifier with Unipolar Oxide TFTs for Heart Rate Measurements" (Poster)
- 11. 23rd International Conference on Solid State Ionics (SSI-23), Boston, USA, July 2022. "Hydrogenated VO₂ Switches for Neuromorphic Functions" (Poster)
- 12. Young Leaders in Displays (HK) and Postgraduate Workshop, Hong Kong, Dec. 2021. "Oxide TFT Frontend Amplifiers for Flexible Sensing Systems" (Oral) (Best Paper Award)
- 13. Society for Information Display's Display Week 2021, virtual conference, May 2021.

 "A Cost-Effective Fluorination Method for Enhancing the Performance of Metal Oxide Thin-Film Transistors Using a Fluorinated Planarization Layer" (Oral) (Distinguished Paper Award)
- 14. 2021 International Conference on Display Technology, Beijing, China, May. 2021. "All-Oxide Thin-Film Transistors for Low-Voltage-Operation Circuits"
- 15. 2019 IEEE 26th International Symposium on Physical and Failure Analysis of Integrated Circuits (IPFA), Hangzhou, China, July 2019.
 - "Output Breakdown Characteristics and the Related Degradation Behaviors in Metal Oxide Thin Film Transistors" (Poster)
 - and "Light-Illumination-Induced Degradation and Its Long-Term Recovery in Indium-Tin-Zinc Oxide Thin-Film Transistors" (Poster)
- 16. Society for Information Display's Display Week 2019, San Jose, USA, May 2019.
 "Stacked PECVD SiO₂ Gate Insulators for Top-Gate Metal Oxide Thin-Film Transistors in Enhancement Operation Mode" (Poster)

 and "Gate-Bias-Stress-Induced Instability in Hybrid-Phase Microstructural ITO-Stabilized ZnO TFTs" (Poster)
- 2018 Postgraduate Workshop on Display Research, Hong Kong, Dec. 2018.
 "Gate Insulator Engineering in Top-Gated ITO-Stabilized ZnO TFTs" (Poster) (Best Poster Presentation Award)
- 18. 2018 IEEE International Conference on Electron Devices and Solid-State Circuits, Shenzhen, China, June 2018.
 - "Vertical Channel ITO-stabilized ZnO Thin-Film Transistors" (Oral) and "Degradation Behaviors of Driving Thin-Film Transistors in Active-Matrix Organic Light-Emitting Diode Displays" (Poster)
- 19. Society for Information Display's Display Week 2018, Log Angeles, USA, May 2018. "Towards High-Performance and Cost-Effective Top-Gated Oxide TFTs with Hybrid-Phase

- Microstructural Channels" (Poster)
- 20. 2018 International Conference on Display Technology, Guangzhou, China, Apr. 2018.
 - "Back-Channel-Etched Oxide TFTs with Hybrid-Phase Microstructural ITO-Stabilized ZnO Channels" (Poster)
 - "Characterization of Self-Aligned Top-Gate Microcrystalline Silicon Thin Film Transistors" (Poster)
 - "Photoluminescence and Electrical Properties study of ITO-stabilized ZnO Thin-Film Transistors with different annealing temperatures" (Poster)
 - and "Transparent Basic Logic Circuits with ITO-Stabilized ZnO Thin Film Transistors" (Poster)
- 21. EuroDisplay 2017, Berlin, Germany, Nov. 2017.
 - "A Study on Hybrid-Phase Microstructural ITO-Stabilized ZnO TFTs with Different Gate Insulators and Electrodes" (Oral)
- 22. 2017 IEEE International Conference on Electron Devices and Solid-State Circuits, Hsinchu, Taiwan, Oct. 2017.
 - "A study on the bottom-gate ITO-stabilized ZnO thin-film transistors" (Poster)
- 23. *The International Display Manufacturing Conference*, Taipei, Taiwan, Sept. 2017. "Self-Aligned Hybrid-Phase Microstructural ITO-Stabilized ZnO TFTs Achieved via a Combination of PECVD Processes" (Poster) (Distinguished Poster Award)
- 24. 2017 International Conference on Display Technology, Fuzhou, China, Feb. 2017. "High Performance Thin-film Transistors with Hybrid-phase ITO-stabilized ZnO Active Channel Layer"
- 25. 23rd International Display Workshops & Asian Display, Fukuoka, Japan, Dec. 2016. "Achievement of High-Performance and Environmentally Stable TFTs by Introducing Hybrid-Phase Microstructure into InSnZnO Channels"
- 26. 7th International Conference on Computer Aided Design for Thin-Film Transistors, Beijing, China, Oct. 2016
 - "Hybrid-Phase Microstructure in InSnZnO Thin Film and Its Application to High-Performance TFT" (Poster)
- 27. 2016 Postgraduate Workshop on Display Research, Guangzhou, China, Sept. 2016. "Hybrid-Phase Microstructure in Indium-Tin-Zinc-Oxide Thin Films and Its Application to High-Performance Thin-film Transistors" (Oral) (Best Oral Presentation Award)
- 28. The International Display Manufacturing Conference, Taipei, Taiwan, Aug. 2015.

 "Fabrication of High-Performance Bridged-Grain Polycrystalline Silicon Thin-Film Transistors with Laser Interference Lithography Technology" (Oral) (Distinguished Paper Award)

 and "Bridged-Grain Metal-Induced Crystallization Poly-Si TFTs with Silicon Self-Implantation" (Poster)
- Patents (3 issued, 3 to be issued)
- Chen Rongsheng, **Deng Sunbin**, Kwok Hoi Sing, "Method for Manufacturing a Top-Gate Self-Aligned Indium-Tin-Zinc Oxide Thin-Film Transistor", United States Patent No.: US 11,049,881 B2, Issue Date: 2021 Jun 29.
- Chen Rongsheng, **Deng Sunbin**, Kwok Hoi Sing, "Inorganic Metallic Oxide Thin Film with Composite Crystal Form and Manufacturing Method Thereof", United States Pub. No.: US 2020/0350167 A1, Pub. Date: Nov. 05, 2020.
- 3. 一种自对准顶栅铟锡锌氧化物薄膜晶体管及其制造方法,陈荣盛,**邓孙斌**,郭海成,Chinese Invention Patent No.: ZL 201710792095.9, Issue Date: Oct. 11, 2019.
- 4. 一种二硫化钼薄膜的制备方法,陈荣盛,钟伟,**邓孙斌**,李国元,吴朝晖,李斌,Chinese Invention Patent No.: ZL 201910049361.8, Issue Date: Aug. 28, 2020.

- 5. 垂直结构的复合晶型金属氧化物薄膜晶体管及其制造方法, 陈荣盛, 尹雪梅, 李国元, **邓孙斌**, 郭海成, Chinese patent application No.: 2019 1 0975945.8, Pub. Date: Oct. 15, 2019.
- 6. 一种金属氧化物薄膜晶体管及其钝化层的制备方法, 陈荣盛, 钟伟, **邓孙斌**, 尹雪梅, 郭海成, Chinese patent application No.: 2018 1 1405391.X, Pub. Date: Nov. 23, 2018.

TECHNICAL SKILLS & QUALIFICATION

- Lab Skills
- 1. Skilled in nanofabrication techniques including, but not limited to, the following:
 - a) Film growth/deposition (sputtering, EBE, PLD, PECVD, ALD, thermal diffusion, implantation, etc.)
 - b) Lithography (photolithography, e-beam lithography, laser-interference lithography, etc.)
 - c) Dry/wet etching (RIE, ICP, DRIE, etc.) and chemical-mechanical polishing
- 2. Skilled in layout design (L-edit, Klayout, etc.), device characterizations (Keithley 4200A-SCS, Keysight B1500A, etc.), and data analysis
- 3. Experienced with material characterizations (XPS, UPS, XRD, SIMS, AFM, SEM, TEM, etc.)
- 4. Experienced with device modelling and circuit simulation toolkits (Silvaco TCAD, Cadence, etc.)
- Qualification
- 1. Grade II (C language) & Grade IV (Network Engineer), National Computer Rank Examination of China
- 2. Second-grade Referee, China Tennis Association

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